

ABSTRACT OF THE DISCLOSURE

A method for forming a pattern of a liquid crystal display (LCD) device includes providing a cliché having at least a first groove structure having a first width and a second groove structure having a second width equal to at least a multiple of the first width and an interval, filling a resist material into the first and second groove structures of the cliché, and applying the resist material filled into the first and second groove structures of the cliché onto an etching object layer of a substrate.